

1 **Supporting Information**

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3 **Highly Efficient CsPbIBr<sub>2</sub> Perovskite Solar Cells with Efficiency Over 9.8% Using Preheating-**  
4 **Assisted Spin-Coating Method**

5 Yuxiao Guo, Xingtian Yin\*, Jie Liu and Wenxiu Que\*

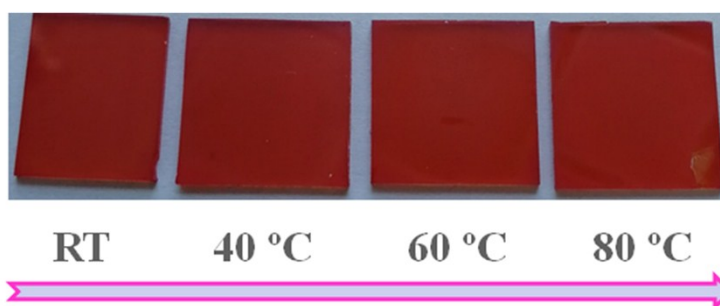
6 *Electronic Materials Research Laboratory, Key Laboratory of the Ministry of Education, International*  
7 *Center for Dielectric Research, Shaanxi Engineering Research Center of Advanced Energy Materials*  
8 *and Devices, School of Electronic & Information Engineering, Xi'an Jiaotong University, Xi'an*  
9 *710049, Shaanxi, People's Republic of China*

10 \*Corresponding author: xt\_yin@mail.xjtu.edu.cn (X. Yin) wxque@mail.xjtu.edu.cn (W. Que)

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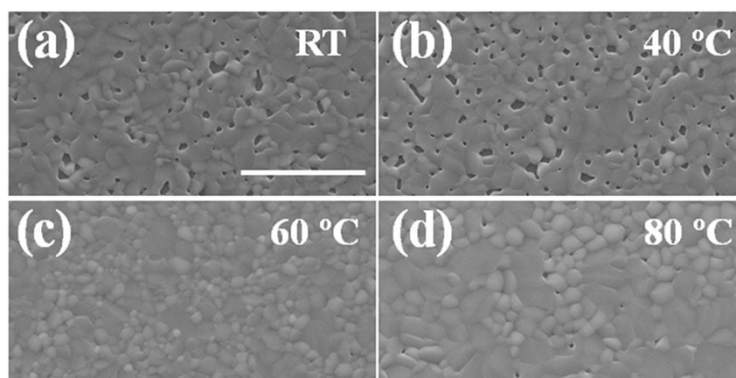
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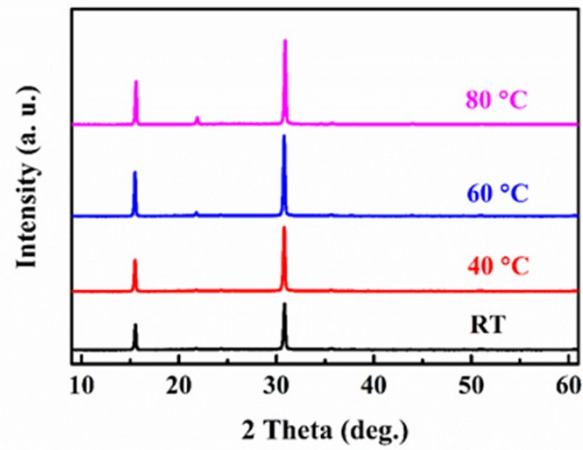
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15 **Fig. S1** Optical images of CsPbIBr<sub>2</sub> films formed at different substrate preheating temperatures.



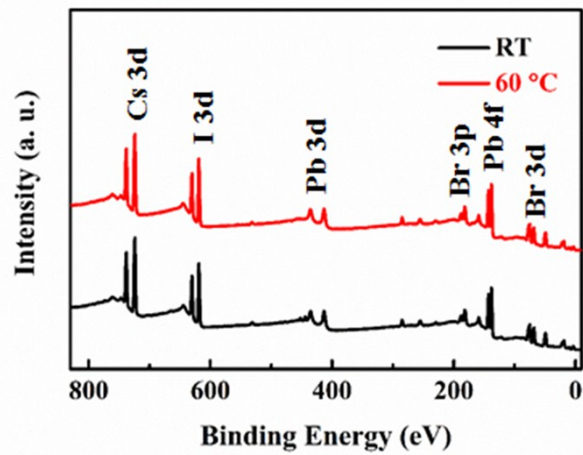
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17 **Fig. S2** Large-scale top-view SEM images of CsPbIBr<sub>2</sub> films formed at different substrate preheating  
18 temperatures, the scale bar is 10 μm.



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2 **Fig. S3** XRD patterns of CsPbIBr<sub>2</sub> films formed at different substrate preheating temperatures.

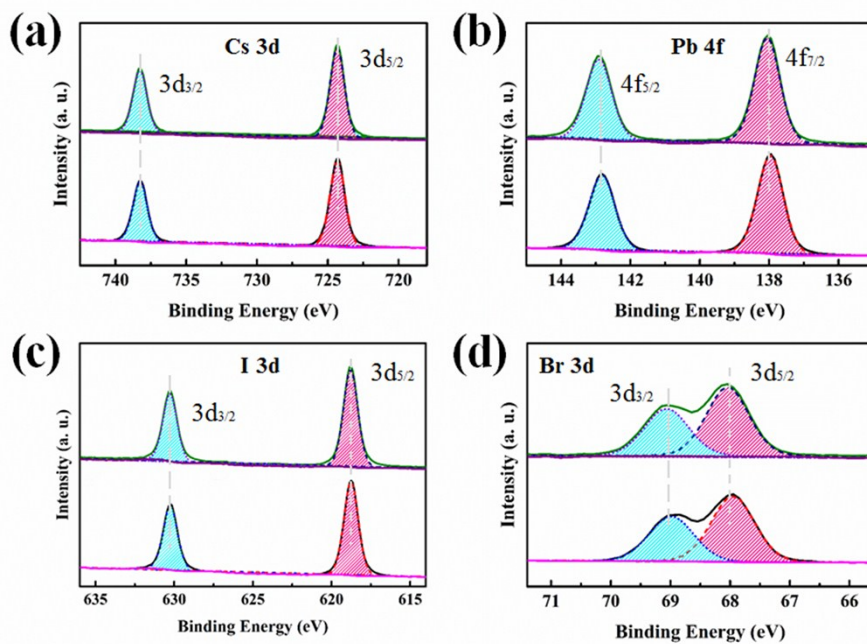


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4 **Fig. S4** XPS survey spectra of CsPbIBr<sub>2</sub> films formed at RT and a substrate preheating temperature of

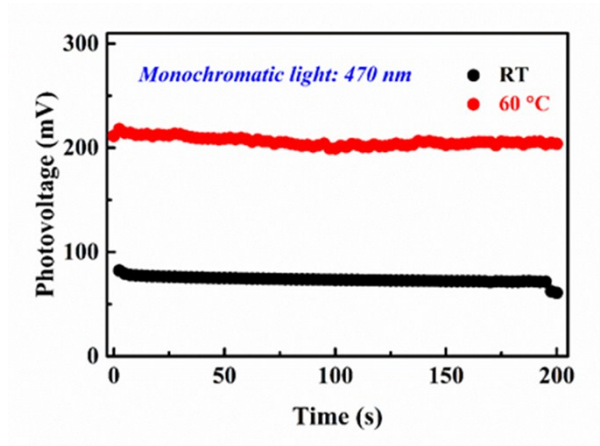
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60 °C, respectively.

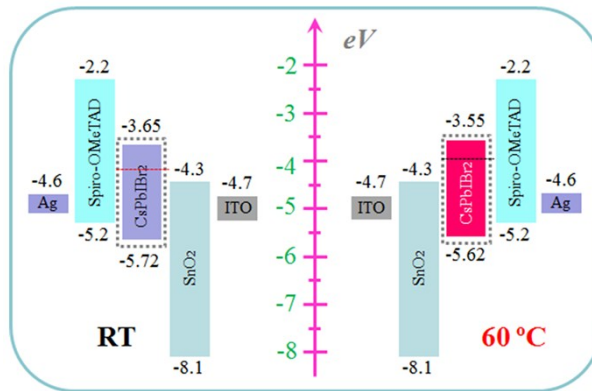


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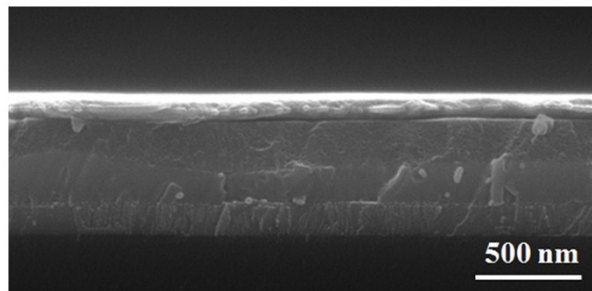
1 **Fig. S5** (a) Cs 3d, (b) Pb 4f, (c) I 3d and (d) Br 3d XPS core spectra of CsPbIBr<sub>2</sub> films formed at RT  
2 (below) and a substrate preheating temperature of 60 °C (above), respectively.



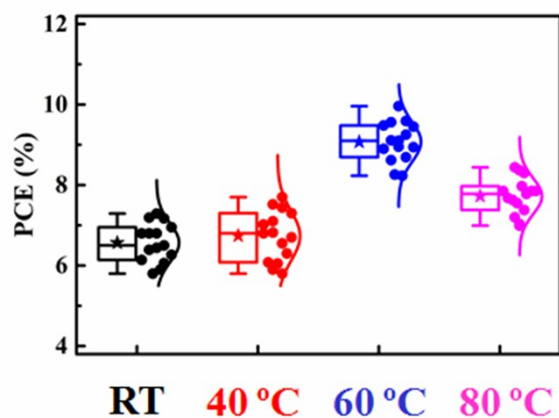
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4 **Fig. S6** SPV measurements of CsPbIBr<sub>2</sub> films formed at RT and a substrate preheating temperature of  
5 60 °C, respectively.



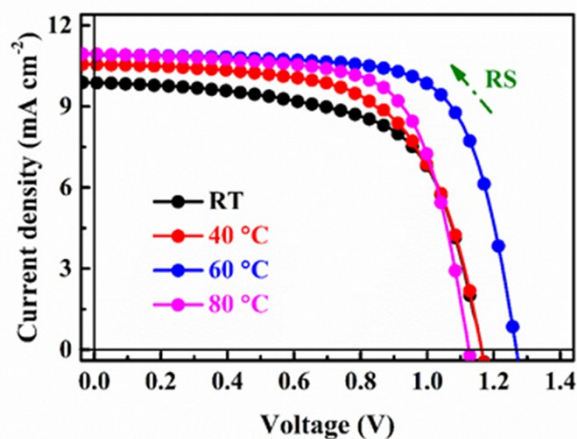
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7 **Fig. S7** Energy level diagrams of the devices based on CsPbIBr<sub>2</sub> films formed at RT and a substrate  
8 preheating temperature of 60 °C, respectively. The dot line indicates the fermi level of  
9 perovskites.



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11 **Fig. S8** Cross-sectional SEM image without color of the corresponding PSC structure.



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 2 **Fig. S9** Statistic PCEs distributions of 15 independent cells over CsPbIBr<sub>2</sub> formed at different substrate  
 3 preheating temperatures.



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 5 **Fig. S10** J-V curves of the champion cells over CsPbIBr<sub>2</sub> formed at different substrate preheating  
 6 temperatures.

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 8 **Table S1** Photovoltaic parameters of the champion devices over CsPbIBr<sub>2</sub> formed at different substrate  
 9 preheating temperatures.

Substrate preheating temperature	V <sub>oc</sub> (V)	J <sub>sc</sub> (mA cm <sup>-2</sup> )	FF	PCE (%)
RT	9.88	1.165	0.63	7.29
40 °C	10.55	1.162	0.63	7.70
60 °C	10.92	1.267	0.71	9.86
80 °C	10.94	1.125	0.69	8.44

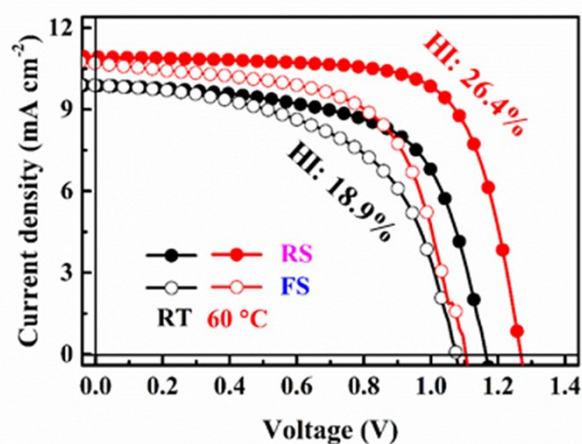
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11 **Table S2** The reported parameters of the cells over pure CsPbIBr<sub>2</sub> perovskite (measured under RS).

Cell structure	Perovskite fabrication method	V <sub>oc</sub> (V)	PCE (%)	Ref.
FTO/TiO <sub>2</sub> /SmBr <sub>3</sub> /CsPbIBr <sub>2</sub> / Spiro-OMeTAD/Au	One-step spin coating	1.170	10.88	1
FTO/TiO <sub>2</sub> (CsBr)/CsPbIBr <sub>2</sub> /Carbon	One-step spin coating & Intermolecular exchange	1.261	10.71	2
FTO/c-TiO <sub>2</sub> /CsPbIBr <sub>2</sub> /Carbon	One-step spin coating	1.171	5.49	3
	One-step spin coating & Intermolecular exchange	1.245	9.16	
FTO/NiO <sub>x</sub> /CsPbIBr <sub>2</sub> /MoO <sub>x</sub> /Au	One-step spin coating	0.850	5.52	4
FTO/c-TiO <sub>2</sub> /CsPbIBr <sub>2</sub> / Spiro-OMeTAD/Au	One-step spin coating (Gas-assisted)	1.227	8.02	5
FTO/c-TiO <sub>2</sub> /CsPbIBr <sub>2</sub> /Au	Dual source evaporation	0.959	4.7	6
ITO/SnO <sub>2</sub> /C <sub>60</sub> /CsPbIBr <sub>2</sub> / Spiro-OMeTAD/Au	One-step spin coating (Antisolvent: chlorobenzene)	1.180	7.34	7
ITO/SnO <sub>2</sub> /CsPbIBr <sub>2</sub> / Spiro-OMeTAD/Ag	One-step spin coating	1.165	7.29	<b>This work</b>
	One-step spin coating (Preheating-assist)	1.267	9.86	
ITO/In <sub>2</sub> S <sub>3</sub> /CsPbIBr <sub>2</sub> / Spiro-OMeTAD/Au	One-step spin coating	1.090	5.59	8
FTO/c-TiO <sub>2</sub> / CsPbIBr <sub>2</sub> /Carbon	One-step spin coating	1.114	5.82	9
	One-step spin coating (Light Processing)	1.283	8.60	
ITO/SnO <sub>2</sub> /CsPbIBr <sub>2</sub> /Carbon	One-step spin coating	1.230	7.00	10
FTO/c-TiO <sub>2</sub> /CsPbIBr <sub>2</sub> /spiro-OMeTAD/Au	One-step spin coating	1.100	6.36	11
	One-step spin coating (PEG-passivation)	1.280	7.31	
FTO/c-TiO <sub>2</sub> /CsPbIBr <sub>2</sub> /carbon	One-step spin coating (Precursor aging)	1.142	6.55	12
FTO/c-TiO <sub>2</sub> /m-TiO <sub>2</sub> / CsPbIBr <sub>2</sub> /Spiro-OMeTAD/Au	Two-step solution (Spraying assist)	1.127	6.3	13
FTO/c-TiO <sub>2</sub> /m-TiO <sub>2</sub> / CsPbIBr <sub>2</sub> /Carbon	Two-step solution	1.080	8.25	14
FTO/c-TiO <sub>2</sub> /m-TiO <sub>2</sub> / CsPbIBr <sub>2</sub> /Carbon	Two-step solution	0.960	6.14	15

FTO/NiO <sub>x</sub> /CsPbIBr <sub>2</sub> /ZnO/Al	Two-step solution	1.010	5.57	16
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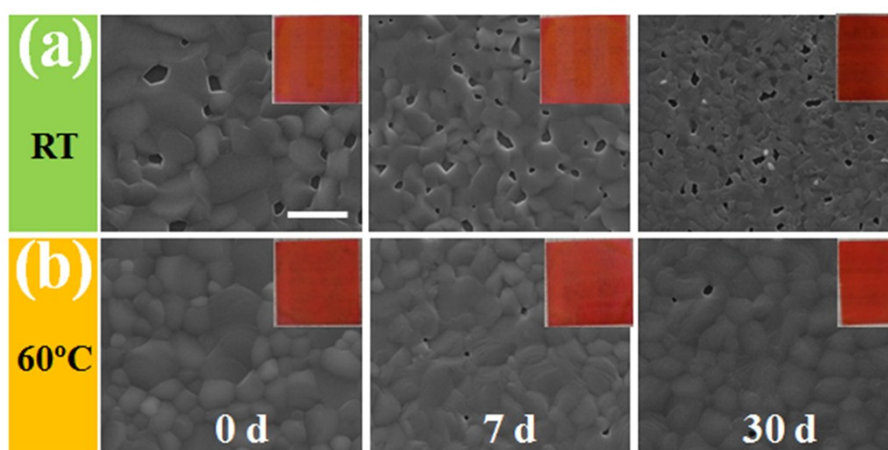
3 **Fig. S11** J-V curves of cells measured under both forward and reverse scan directions.

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5 **Table S3** Summary of the electrochemical impedance spectra (EIS) parameters analyzed in Fig. 4g  
6 with fitting the Nyquist plots.

Substrate preheating temperature	$R_s$ ( $\Omega$ )	Transport resistance ( $R_{tr}$ ) ( $\Omega$ )	Recombination resistance ( $R_{rec}$ ) ( $\Omega$ )
RT	8.6	1140	260
60 °C	6.7	1835	3250

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9 **Fig. S12** The morphological evolution of the CsPbIBr<sub>2</sub> films formed at (a) RT and (b) a substrate  
10 preheating temperature of 60 °C, respectively, under an ambient atmosphere of ~25 °C and  
11 ~35% RH. Insets are pictures of the corresponding perovskite films, and the scale bar is 2  
12  $\mu\text{m}$ .

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